

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/807298	D	430	270.1	355	CLARK

APPLICANTS: Frank Schadt III, Michael Fryd, Mookan Periyasamy
 TITLE: Photoresists and processes for microlithography

PTO-2040 (12/93)

INTERNATIONAL CLASSIFICATION			

Continued on Issue Slip inside File Jacket

<input type="checkbox"/> TERMINAL DISCLAIMER <input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed. <input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent No. _____ <input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drawn	Figs. Drawn	Print Figs	Total Claims	Print Claim for O.G.
				NOTICE OF ALLOWANCE MAILED	
	(Assistant Examiner)	(Date)			
	(Primary Examiner)	(Date)		ISSUE FEE	
				Amount Due	Date Paid
	(Legal Instruments Examiner)	(Date)		ISSUE BATCH NUMBER	

WARNING:
 The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35 Sections 122, 181 and 368. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.

Form PTO-498A (Rev. 6/99)

FILED WITH: ☐ DISK (CRF) ☐ FICHE ☐ CD-ROM

(Attached in pocket on right inside flap)

BEST AVAILABLE COPY